

# 1 Formation of rutile (Cr,Ta,Ti)O<sub>2</sub> oxides during oxidation of refractory high entropy alloys 2 in Ta-Mo-Cr-Ti-Al system

## 3 Authors

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## 29 Abstract:

30 The chemical identity of rutile oxides formed during oxidation of alloys with different Ti content within the Ta-Mo-  
31 Cr-Ti-Al system at 1200°C for 24h was determined. Rutile-type oxide (Cr,Ta,Ti)O<sub>2</sub> was observed on  
32 20Ta20Mo20Cr20Ti20Al and 67.5(TaMoCr)10Ti22.5Al (at.%). Based on the experimental results, the valence states  
33 of Cr, Ta and Ti were unequivocally determined. Higher concentrations of Ti in (Cr,Ta,Ti)O<sub>2</sub> lead to the formation  
34 of thinner oxide scales and zones of internal corrosion. It is concluded that the occupation of higher-valent Ti<sup>4+</sup>  
35 cations on the Cr<sup>3+</sup> sub-lattice reduces the oxygen vacancy concentration and thus improves the oxidation behaviour  
36 of n-type conducting (Cr,Ta,Ti)O<sub>2</sub>-forming alloys.

37 **Keywords:** refractory high entropy alloy, rutile (Cr,Ta)O<sub>2</sub>, rutile (Cr,Ta,Ti)O<sub>2</sub>, oxidation state analysis, TEM-EELS

## 38 Highlights

39 Cation oxidation states of (Cr,Ta,Ti)O<sub>2</sub>, formed on alloys in the Ta-Mo-Cr-Ti-Al system were determined by  
40 electron energy-loss spectroscopy.

41 The protective properties of rutile (Cr,Ta,Ti)O<sub>2</sub> are discussed based on the Wagner-Hauffe valence approach.

42 A map of the lattice parameters of various transition metal-based rutile oxides is provided.

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44

## 45 1. Introduction

46 Despite their attractive high-temperature strength [1–10], a significant drawback of most Refractory High Entropy  
47 Alloys (RHEAs) represents their poor oxidation behaviour [11–19], attributed to the insufficient oxidation resistance  
48 of pure refractory metals (RMs). Pure and low alloyed RM form porous and fast-growing oxides, like  $\text{WO}_3$  [20,21],  
49  $\text{Nb}_2\text{O}_5$  [22,23] and  $\text{Ta}_2\text{O}_5$  [24], or volatile oxides, like  $\text{V}_2\text{O}_5$  [16,25],  $\text{MoO}_3$  [21,25] and  $\text{WO}_3$  [25,26] depending on  
50 temperature and oxygen partial pressure. In addition, most RMs as well as the group IV elements such as Zr [27],  $\alpha$ -  
51 Hf [28] and  $\alpha$ -Ti [29,30], which are often constituents of RHEAs, possess very high oxygen solubility. But this  
52 property does not apply to RMs such as W [31,32] and Mo [32], which feature a very low oxygen solubility in  
53 contrast. To improve the high-temperature oxidation resistance of RHEAs according to the classical concept, the  
54 elements Cr, Al or Si are added to form protective scales of  $\text{Cr}_2\text{O}_3$ ,  $\text{Al}_2\text{O}_3$  or  $\text{SiO}_2$ , respectively [33–41]. The majority  
55 of common RHEAs form thick, non-protective oxide layers consisting of mixed oxides [14,17–19,42–48]. Zr- and V-  
56 containing RHEAs display the lowest high-temperature oxidation resistance and a high mass gain after oxidation at  
57 1000 °C for 10 h [16–19]. The high oxygen solubility in the metallic bulk of TiZrNbHfTa [48] and  
58 Hf<sub>0.5</sub>Nb<sub>0.5</sub>Ta<sub>0.5</sub>Ti<sub>1.5</sub>Zr [44] in combination with the formation of non-protective  $\text{ZrO}_2$  lead to a pronounced  
59 internal diffusion zone with cracking due to growth stresses and subsequent spallation. In V-containing alloys such  
60 as CrMoNbTaV the formation of liquid or gaseous  $\text{V}_2\text{O}_5$  along with  $\text{MoO}_3$  evaporation prevents the formation of a  
61 protective oxide layer [19]. Even the passivating elements Cr and Al are unable to significantly improve the  
62 oxidation behaviour [17,42,48]. In the case of Nb-containing and W-containing RHEAs, like NbMoCrTiAl [45] and  
63 NbCrVWTa [49], voluminous  $\text{Nb}_2\text{O}_5$  (Pilling Bedworth ratio; PBR = 2.5) and  $\text{WO}_3$  (PBR = 3.3) are observed, which  
64 lead to rupture of the oxide layer and accelerate oxygen inward diffusion. The reason for the non-protective  
65 properties of the Nb-containing oxides is probably related to multiple polymorphic modifications of  $\text{Nb}_2\text{O}_5$  [50,51].  
66 Especially the  $\beta$ - $\text{Nb}_2\text{O}_5$  modification is known for the highest volume expansion and causing crack formation and  
67 chipping [45,52,53]. The multifarious formation of complex oxides such as  $\text{Cr}_2\text{TiO}_5$  [18],  $\text{TiNb}_2\text{O}_7$  [17],  
68  $(\text{Ti}_{1.5}\text{Ta}_{0.5}\text{Nb}_{0.5}\text{Hf}_{0.5}\text{Zr})\text{O}_8$  [44],  $\text{Nb}_2\text{Zr}_6\text{O}_{17}$  [17],  $(\text{Ti,Cr,Nb})\text{O}_2$  [54] or  $\text{CrVNbO}_6$  [54] is reported. However, those as  
69 well do not offer protection against severe oxidation. Only a very few RHEAs are capable of forming protective  
70 oxide scales [45,55,56]. The formation of a protective  $\text{Al}_2\text{O}_3$  layer was exclusively reported for  
71  $\text{Nb}_{1.3}\text{Si}_{2.4}\text{Ti}_{2.4}\text{Al}_{3.5}\text{Hf}_{0.4}$  after oxidation at 1200 °C for 100 h [56]. Moreover, some Cr-, Al-, Ta- and Ti-containing  
72 RHEAs demonstrate considerable oxidation resistance [45–47,55,57]. In those cases, the beneficial effect on the  
73 oxidation behaviour is attributed to the chemical reaction of simple oxides to the more complex ones [45–47,55,57].  
74 The 13.4Ta15.2Nb20.3Mo25.2Cr5.4Ti17.6Al2.9Si (at.%) is protected against catastrophic oxidation by the  
75 formation of a rutile  $\text{CrTaO}_4$  based oxide layer during oxidation at both 1000 °C and 1100 °C for 200 h [55]. Our  
76 preliminary studies on TaMoCrTiAl indicate that a protective rutile Cr-Ta oxide layer acts as a barrier to cation  
77 outward diffusion and in conjunction reduces oxygen inward diffusion in the temperature range of 500 °C – 1500°C  
78 [45,47,58]. However, the protective properties of complex oxide grown on RHEAs have not been understood in  
79 detail. The previous studies reveal that a complex rutile Cr-Ta oxide is formed during the oxidation of TaMoCrTiAl  
80 at 1200 °C for 24 h, whereby a considerable amount of Ti is dissolved in such [45,47]. Transition metals like Ti  
81 within those oxides are known to adapt to different oxidation states, e.g.  $\text{Ti}^{2+}$  in  $\text{TiO}$ ,  $\text{Ti}^{3+}$  in  $\text{Ti}_2\text{O}_3$ , or  $\text{Ti}^{4+}$  in  $\text{TiO}_2$   
82 [59]. The stoichiometry, the oxidation states as well as the defect structure of the rutile Cr-Ta-Ti oxide formed on the  
83 equiatomic alloy Ta-Mo-Cr-Ti-Al are not clear yet.

84 In this work, chemical stoichiometry and the oxidation states with in the respective rutile Cr-Ti-Ta oxides grown on  
85 RHEAs with varying Ti contents, i.e. 20Ta20Mo20Cr20Ti20Al, 67.5(TaMoCr)10Ti22.5Al, 25Ta25Mo25Cr25Al  
86 (at.%) are determined and correlated to their oxidation resistance. Particularly, the impact of Ti on the protective  
87 properties of oxide scales was clarified. To generally understand the nature of the oxides formed in mentioned alloys  
88 within the Ta-Mo-Cr-Ti-Al system, additional alloys 20Ta80Cr (at.%) and equimolar TaCrTi were manufactured,  
89 oxidized and their scales investigated by X-ray diffraction (XRD) and transmission electron microscopy (TEM). The  
90 microstructure of both additional alloys as well as the oxidation kinetics were not thoroughly studied. The additional  
91 alloy 20Ta80Cr was selected because is known to form a Cr-Ta oxide on the Laves phase underneath a covering  
92  $\text{Cr}_2\text{O}_3$  top layer during oxidation at 1100 °C for 24 h [60]. The alloy TaCrTi is related to the elements Ta, Cr, Ti,  
93 which are the constituents of rutile Ta-Cr-Ti oxide. To achieve the objective stated above, a cross-scale materials  
94 analysis is applied, including STEM-EELS electron energy-loss spectroscopy (EELS) in combination with scanning  
95 transmission electron microscopy (STEM) [61–63]. The oxidation products of two additional alloys (20Ta80Cr and  
96 TaCrTi) in combination with  $\text{Cr}_2\text{O}_3$ ,  $\text{Ta}_2\text{O}_5$ , and  $\text{TiO}_2$  powders provide EELS references to unambiguously identify  
97 the oxidation states of formed rutile Cr-Ta-(Ti) oxides on high entropy alloys in Ta-Mo-Cr-Ti-Al system. The

98 oxidation states as well as quantitative energy dispersive X-Ray spectroscopy in STEM (STEM-EDX) serve as a  
 99 basis for the discussion of the protective properties of the different formed oxides.

100

## 101 2. Experimental Procedures

102  
 103 All investigated alloys were manufactured from elemental bulk material by arc melting (AM/0,5 Arc melting furnace  
 104 by company Edmund Bühler GmbH). The pure elements Ta, Mo, Cr, Ti and Al were supplied by chemPUR GmbH.  
 105 Purities of the elements Ta, Mo, Cr, Ti and Al are 99.9, 99.95, 99.99, 99.8 and 99.99 %, respectively. The elements  
 106 were carefully weighed according to the desired chemical composition of the alloys and (re-)melted at least five  
 107 times under  $\approx 0.6$  atm of Ar in the water-cooled mold of the arc melter. To dissolve the dendritic microstructure, all  
 108 alloys were homogenized at 1500 °C for 20 h in flowing Ar protective gas (HTRT 70-600/18 tube furnace by  
 109 Carbolite Gero GmbH & Co. KG). Subsequently, the alloys were cooled down to room temperature in the furnace.  
 110 The applied heating and cooling rates were 250 K/h. The chemical compositions of the alloys were confirmed by  
 111 inductively coupled plasma optical emission spectrometry (ICP-OES) (TaMoCrTiAl [47]) as well as energy  
 112 dispersive X-ray spectroscopy in the scanning electron microscope (SEM-EDX; k-factors provided in the employed  
 113 software TEAM™ V4.5.1 see Table 1). The ICP-OES results of TaMoCrTiAl served as a reference for the SEM-  
 114 EDX measurements of the alloy samples. All alloy compositions are in very well agreement with the desired  
 115 compositions within the maximum deviation of 0.5 %.

116  
 117 **Table 1:** Chemical composition  $\bar{x}$  [at. %] of investigated alloys in annealed condition (1500 °C, 20 h) as derived from SEM-EDX.  
 118 (Only the chemical composition of TaMoCrTiAl was determined by ICP-OES). The chemical composition of TaMoCrTiAl was  
 119 taken from [47] and corresponds to the same batch.

alloy	chemical concentrations $\bar{x}$ of the investigated alloys [at. %]				
	Ta	Mo	Cr	Ti	Al
TaMoCrTiAl	20.1	19.5	19.8	20.4	20.2
TaMoCr10TiAl	22.6	22.4	22.6	10.1	22.3
TaMoCrAl	24.9	25.3	24.8	-	25.0
additional alloy TaCrTi	33.7	-	33.1	33.2	-
additional alloy 20Ta80Cr	20.2	-	79.8	-	-

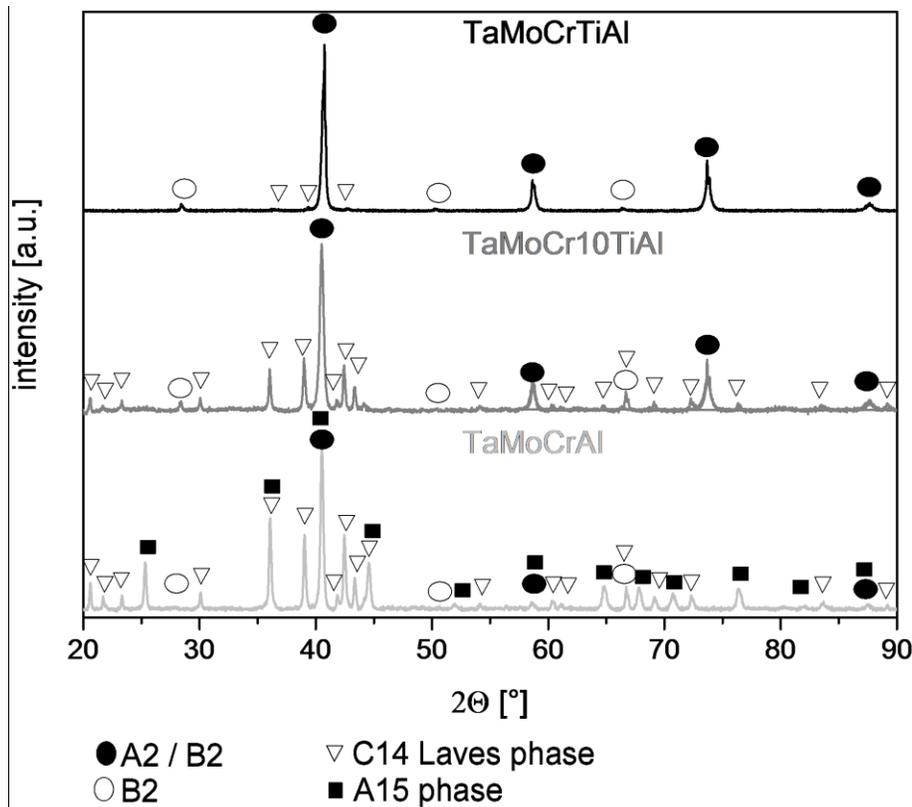
120  
 121 Samples for the oxidation experiments were taken from the bulk by electrical discharge machining (EDM) and  
 122 ground to grit P1200. Immediately before the each oxidation experiment, the samples were cleaned in ethanol by  
 123 ultrasonication. Samples for cross-sectional SEM analyses were ground to P4000 grit using SiC papers, followed by  
 124 vibratory polishing (2 h with 50 % amplitude) with a 0.1  $\mu\text{m}$  diamond suspension. Oxidation mass change curves  
 125 were recorded isothermally at 1200 °C with a Rubotherm thermogravimetric system (TGA) in laboratory air.  
 126 Additional isothermal oxidation tests were performed in a muffle furnace at 1200 °C for 30 min. For XRD analysis,  
 127 the formed oxide layer of the alloys was first mechanically removed with a scalpel and crushed with a pestle and  
 128 mortar. Finally, the powder was sieved to a particle size of 40  $\mu\text{m}$ . The diffractograms were recorded on an X'Pert  
 129 Pro MPD diffraction device equipped with a Cu-K $\alpha$  tube operated at 45 kV / 40 mA and X-ray detector X'Celerator  
 130 based on RTMS (real time multiple strip) technology. The scanning was performed in a  $2\theta$  range of 20° – 90° at a  
 131 step size of 0.005° and a count time of 500 s / step. The lattice parameters were determined using the unit cell lattice  
 132 parameter refinement module of the PANalytical X'Pert HighScore 4.1 software utilizing default profile fit  
 133 ( $R_{\text{expected}}^2 / R_{\text{weighted profile}}^2 < 2$ ) and specimen displacement to minimize the influence of systematic errors. Detailed  
 134 information can be found in Ref. [64]. Cross-sectional microstructural and chemical analysis of the alloys and the  
 135 oxidized samples were performed with a dual-beam focused ion beam - scanning electron microscope (FIB-SEM)  
 136 system FEI Helios Nanolab 600 equipped with multiple detectors for backscattered electron (BSE) imaging and  
 137 EDX. The volume fraction of each phase and the mean thickness of the different oxide layers were evaluated based

138 on 20 individual BSE measurements images using the software ImageJ. The area fractions of the phases were  
139 obtained by binarization of the images. Area and volume fractions are considered equal under the assumption of  
140 isotropy and isometry. Site-specific TEM lift-out samples from the oxide layer were prepared using the FEI Helios  
141 Nanolab 600 FiB-SEM system through ion milling with Ga<sup>+</sup> ions at acceleration voltages of 5-30 kV depending on  
142 the lamella thickness. (Scanning) TEM investigations were performed on a FEI Talos F200X operated at an  
143 acceleration voltage of 200 kV. The instrument is equipped with multiple detectors for STEM imaging, a XFEG  
144 high-brightness gun, a large-area Super-X EDX detector, and a Gatan Continuum ER spectrometer. The  
145 microstructure and chemical composition of the individual oxides were analyzed by high-angle annular dark-field  
146 STEM (HAADF-STEM) in combination with STEM-EDX (EDX; k-factors provided in the used software Velox  
147 V.3.1.0). Electron energy-loss spectroscopy (EELS) was performed to determine the oxidation states of the cations in  
148 the formed oxides (ratio convergence to acceptance angle around 2). To record the Ti-L<sub>3,2</sub>, O-K and Cr-L<sub>3,2</sub>  
149 ionization edges in a single spectrum, the core-loss region was set to 390 - 700 eV at a dispersion of 0.15  
150 eV/channel. The Ta-M<sub>5,4</sub> and Ta-M<sub>3</sub> ionization edges were recorded in the energy-loss range of 1670 - 2280 eV at  
151 0.3 eV/channel. The low-loss spectra, simultaneously recorded with the respective core losses in dual-EELS-mode,  
152 were used to calibrate the energy loss and to determine the relative sample thickness  $\lambda / t$  ( $\lambda / t = 0.3 - 0.5$  for all  
153 TEM lamellae). To record reference spectra for the metal ionization edges the pure oxides, namely TiO<sub>2</sub> (Ti<sup>4+</sup>)  
154 powder (rutile, purity: 99.99 %, metals basis) and Cr<sub>2</sub>O<sub>3</sub> (Cr<sup>3+</sup>) powder (corundum, purity: 99.97 %, metals basis)  
155 were purchased from Thermo Fischer GmbH. MaTeck GmbH provided Ta<sub>2</sub>O<sub>5</sub> (Ta<sup>5+</sup>) powder (orthorhombic, purity:  
156 99.99 %). To avoid contamination during the TEM examinations, all samples were cleaned in the Plasma Cleaner  
157 NanoClean Model 1070. The values of the standard free enthalpy of the relevant oxides at the temperature of 1200  
158 °C were calculated using the SGPS database of the FactSage V.8 software.  
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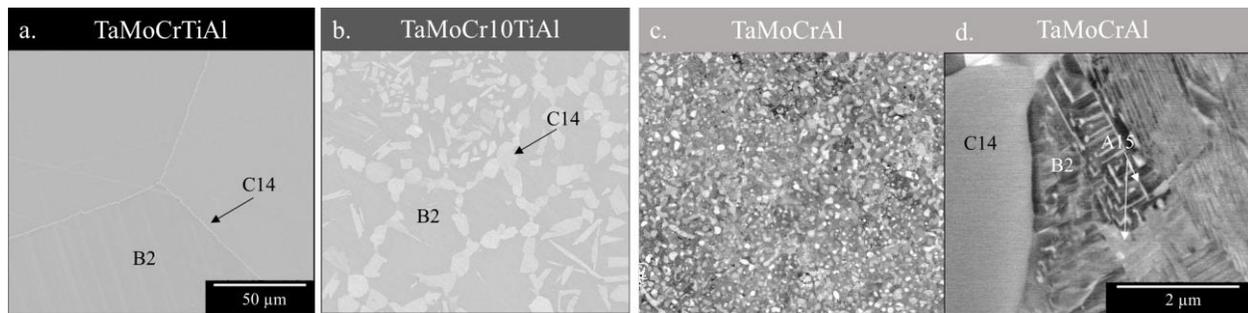
### 160 3. Results

#### 161 3.1 Microstructure

162 The microstructures of TaMoCrTiAl and TaMoCrAl were already presented in previous publications [45,47,65]. The  
163 powder XRD analysis in Fig. 1 of all investigated alloys revealed two phases, namely (i) a C14-type Laves phase  
164 (Cr<sub>2</sub>Ta) and (ii) an ordered B2-type crystal structure. The B2 super lattice peaks are indicated in addition to the  
165 fundamental A2-type peaks by open circles. Only TaMoCrAl contains the additional A15 phase (Mo<sub>3</sub>Al; closed  
166 square labels). The BSE-SEM images in Fig. 2 illustrate the morphology of the individual phases. The A15 phase is  
167 expected to feature the highest intensity due to the high content of Mo, while a medium intensity is anticipated for  
168 the Laves phase Cr<sub>2</sub>Ta. TaMoCrTiAl consists of large B2 grains. Along the grain boundaries, the Laves phase is  
169 precipitated. The Laves phase volume fraction was reported earlier to be 0.4 vol. % [47]. Reducing the Ti content to  
170 10 at. % (TaMoCr10TiAl) results in a two-phase microstructure of B2 phase and Laves phase; the volume fractions  
171 are approximately 68 vol. % and 32 vol. %, respectively. TaMoCrAl possesses a three-phase microstructure after  
172 heat treatment, containing Laves phase C14 in addition to B2 and A15 [45]. Laves phase C14 predominates in this  
173 alloy with about 65 vol. % [45]. At higher magnification, the A15 phase (bright contrast) and the B2 phase (dark  
174 contrast) are identified in Fig. 2 d.  
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176  
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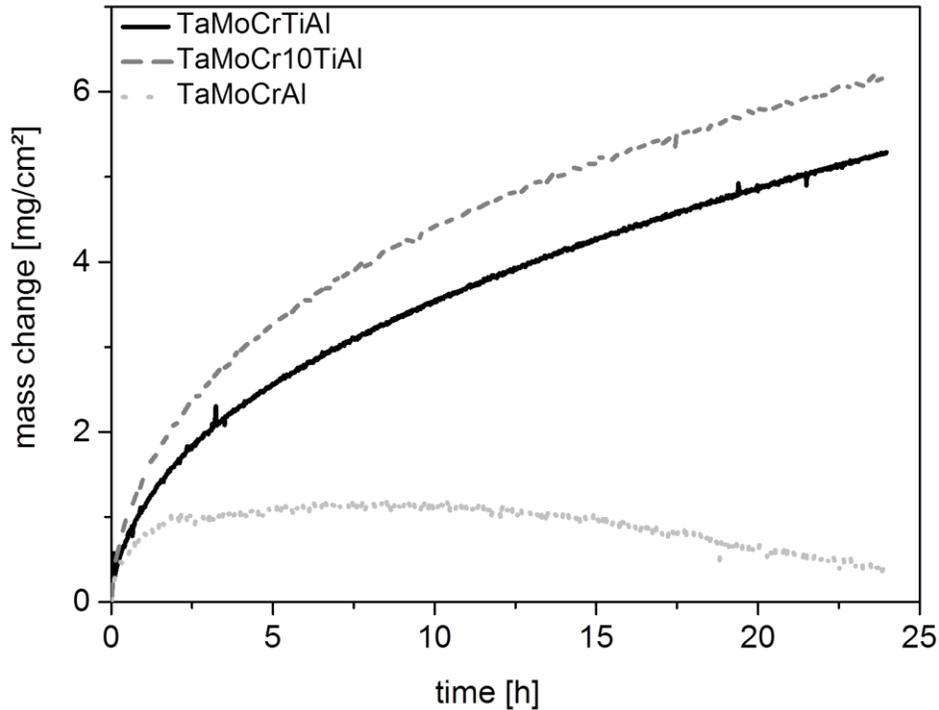
178  
 179 **Fig. 1** Powder XRD pattern of the investigated alloys after homogenization at 1500 °C for 20 h. Closed circles indicate A2 / B2  
 180 Bragg peaks; open circles highlight visible B2 Bragg peaks. TaMoCrTiAl and TaMoCrAl correspond to the samples investigated  
 181 in [45]. The peaks are labeled according to simulated XRD data based on the structures listed in the legend.  
 182



183  
 184 **Fig. 2** BSE-SEM micrographs of the investigated alloys after homogenization 1500 °C / 20h: a. TaMoCrTiAl, b. TaMoCr10TiAl,  
 185 c. TaMoCrAl, d. BSE-SEM image of the TaMoCrAl at higher magnification. All BSE-SEM micrographs, except image d., were  
 186 taken at the same magnification.  
 187

### 188 3.2 Oxidation kinetics

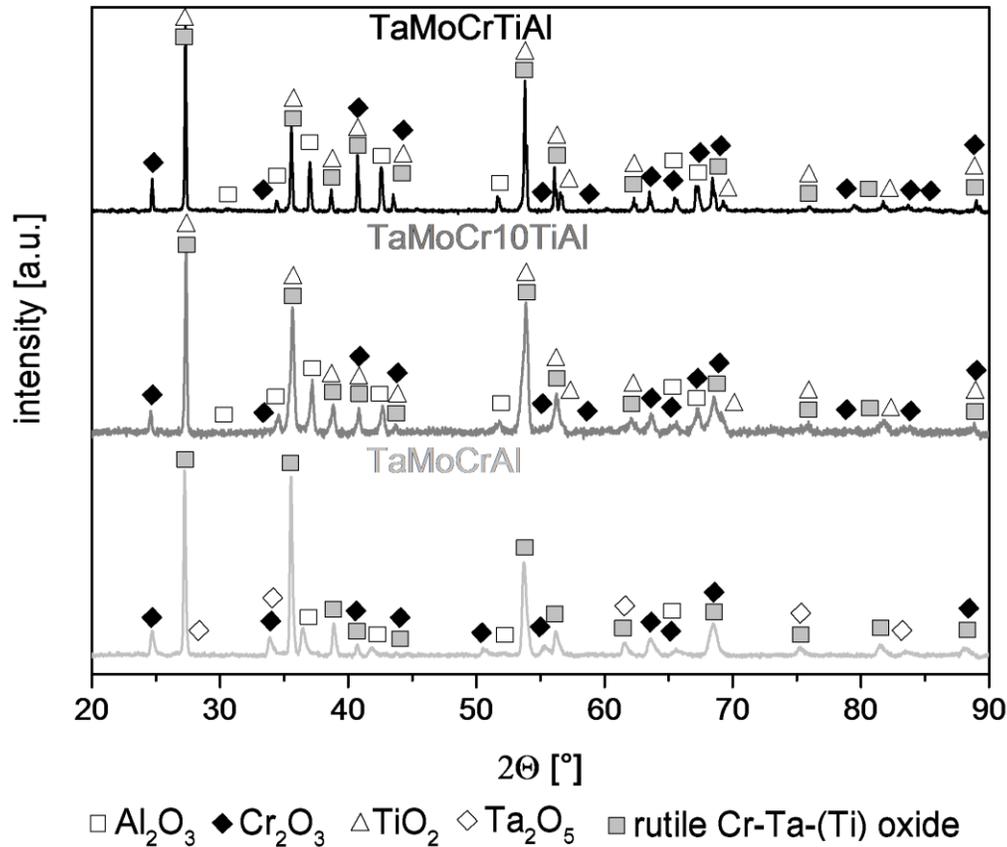
189  
 190 Fig. 3 represents the specific mass changes as a function of time for the alloys with varying Ti contents during  
 191 isothermal exposure to air at 1200 °C. The mass change curve of TaMoCrTiAl is taken from [47]. The oxidation  
 192 kinetics of TaMoCrTiAl obeys a parabolic rate law [47]. The recorded mass gain at a temperature of 1200 after 24 h  
 193 °C is 5.29 mg/cm<sup>2</sup> [47]. In comparison to TaMoCrTiAl, TaMoCr10TiAl exhibits a slightly higher mass change over  
 194 the entire test time. After 24 h oxidation, TaMoCr10TiAl reveals a mass change of 6.19 mg/cm<sup>2</sup>. In contrast, the Ti-  
 195 free alloy displays significantly lower initial kinetics, followed by an increasingly pronounced mass loss over time.  
 196



197  
198 **Fig. 3** Specific mass change as a function of time for investigated alloys during isothermal exposure to air at 1200 °C. The mass  
199 change curve of TaMoCrTiAl is taken from [47].  
200

201  
202 **3.3 Crystallographic analysis of the oxide products**  
203

204 In Fig. 4, the XRD results of the oxides after oxidation at 1200 °C for 24 h are presented. The diffraction pattern of  
205 the oxide products on TaMoCrTiAl reveals Al<sub>2</sub>O<sub>3</sub>, Cr<sub>2</sub>O<sub>3</sub>, TiO<sub>2</sub> and a further rutile-type oxide based on the CrTaO<sub>4</sub>  
206 crystal structure [47]. The rutile-type oxide is referred to as rutile Cr-Ta-(Ti) oxide in the subsequent part of the  
207 results. The XRD measurement of TaMoCrAl, no TiO<sub>2</sub> but Ta<sub>2</sub>O<sub>5</sub> oxide was detected. In addition, the crystal structure of the oxides formed on  
208 the additional alloys TaCrTi and 20Ta80Cr was investigated by XRD. The respective diffraction patterns are given in  
209 the supplementary material Fig S. 1. While Ta<sub>2</sub>O<sub>5</sub>, Cr<sub>2</sub>O<sub>3</sub>, TiO<sub>2</sub> and rutile Cr-Ta-(Ti) oxide were found on the  
210 additional alloy TaCrTi, Cr<sub>2</sub>O<sub>3</sub> and a rutile Cr-Ta oxide were identified on 20Ta80Cr. Table 2 reports the lattice  
211 parameters of rutile Cr-Ta-(Ti) oxide, which were derived from the XRD data in Fig. 4.  
212  
213  
214



215  
216 **Fig. 4** XRD pattern of investigated alloys oxidation at 1200 °C for 24 h in air. The diffraction pattern of TaMoCrTiAl is taken  
217 from [47]. The peaks are labeled according to simulated XRD data based on the structures of the oxides listed in the legend.  
218

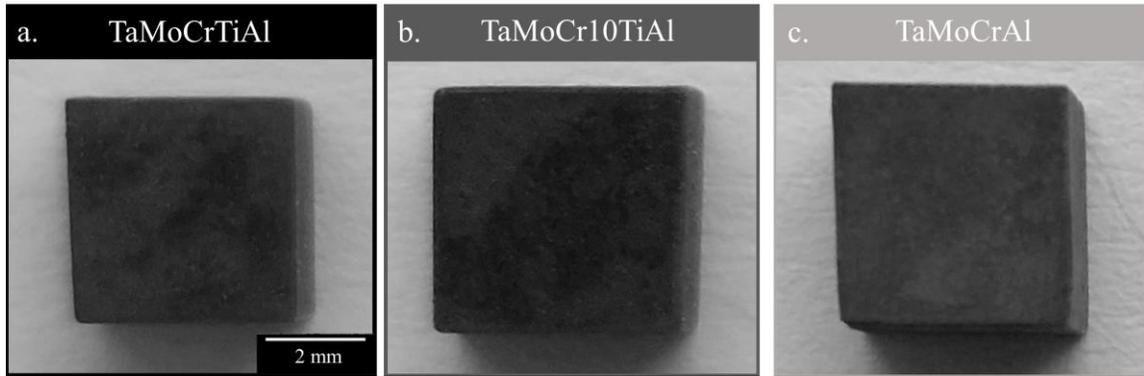
219 **Table 2** Determined lattice parameters from XRD measurements of rutile Cr-Ta-(Ti) oxide after oxidation at 1200 °C for 24 h.  
220 The lattice parameter of rutile Cr-Ta-Ti oxide formed on TaMoCrTiAl is taken from [47].

alloy	rutile Ta-Cr-(Ti) oxide lattice parameter	
	a [Å]	c [Å]
TaMoCrTiAl [47]	4.635	3.011
TaMoCr10TiAl	4.637	3.013
TaMoCrAl	4.642	3.018
additional alloy TaCrTi	4.634	3.007
additional alloy 20Ta80Cr	4.643	3.019

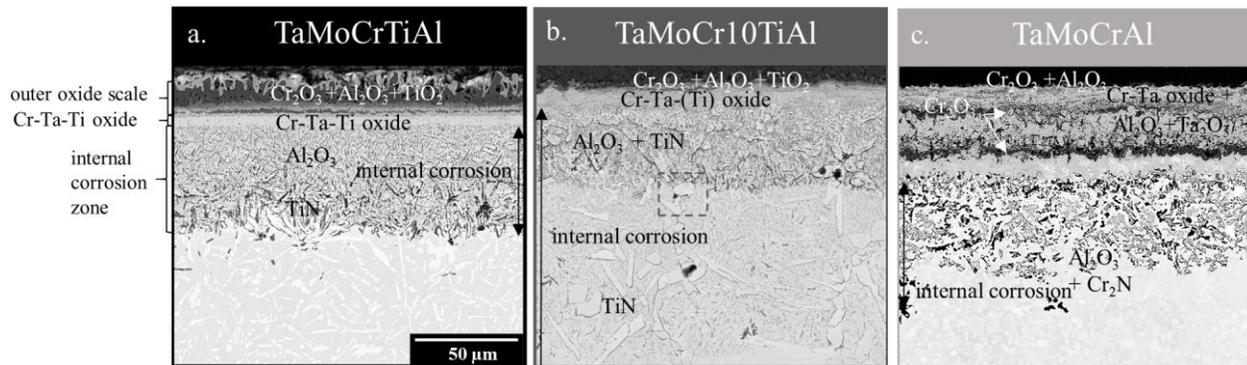
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223 **3.4. Microstructural analysis of oxide scales**  
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225 After the oxidation tests, macroscopic images of the samples were taken (Fig. 5). All samples display an intact oxide  
226 outer scale, no cracks or flaking are visible. Cross-sectional BSE-SEM images of the oxide layers oxidation to air at  
227 1200 °C for 24 h are depicted in Fig. 6. In all cases complex multi-layer oxide structures are visible. A multilayered  
228 oxide scale consisting of outer TiO<sub>2</sub>, Al<sub>2</sub>O<sub>3</sub>, Cr<sub>2</sub>O<sub>3</sub> and inner rutile Cr-Ta-Ti oxide layer as well as an underlying  
229 distinct zone of internal corrosion was reported in our previous studies for TaMoCrTiAl oxidized under the same  
230 conditions [46,47]. Using a marker experiment, it was established that the rutile Cr-Ta-Ti oxide layer at the  
231 oxide/substrate interface grows inwards as a result of oxygen inward diffusion [47]. Beneath the Cr-Ta-Ti oxide  
232 layer, a distinct zone of internal corrosion with Al<sub>2</sub>O<sub>3</sub> and TiN particles is formed [47]. In the present work, by  
233 combining XRD and SEM-EDX (SEM-EDX-mapping Fig S. 2), the same multilayered oxide structure was  
234 identified for oxidized TaMoCr10TiAl. Noticeable decoration of the phase boundaries in the internal corrosion zone  
235 by Al<sub>2</sub>O<sub>3</sub> and TiN particles was observed (see also Fig S. 2 detail image of the dashed frame in Fig. 6 b.). Due to the  
236 absence of Ti in TaMoCrAl, no TiO<sub>2</sub> is formed and, instead, a thin semi-continuous outermost layer of Cr<sub>2</sub>O<sub>3</sub> and

237 underlying  $\text{Al}_2\text{O}_3$  particles is formed (Fig. 6 c.). Beneath, a thick and porous inner layer consisting of a mixture of  
 238 rutile Cr-Ta oxide,  $\text{Ta}_2\text{O}_5$ ,  $\text{Al}_2\text{O}_3$  and  $\text{Cr}_2\text{O}_3$  is observed. Below this, a zone of internal corrosion with  $\text{Al}_2\text{O}_3$  and  
 239  $\text{Cr}_2\text{N}$  particles is present. The formed oxide scale on the alloy TaMoCrAl is in accordance with the investigations of  
 240 Müller et al. [45] after oxidation at 1000 °C for 48 h. In the supplementary material (Fig S. 3), the EDX mapping of  
 241 the alloy TaMoCrAl after oxidation is depicted. Furthermore, detailed images in higher magnification of the outer  
 242 oxide layers formed on TaMoCr10TiAl and TaMoCrAl are provided in supplementary material Fig S. 4 and Fig S.  
 243 5, respectively.  
 244



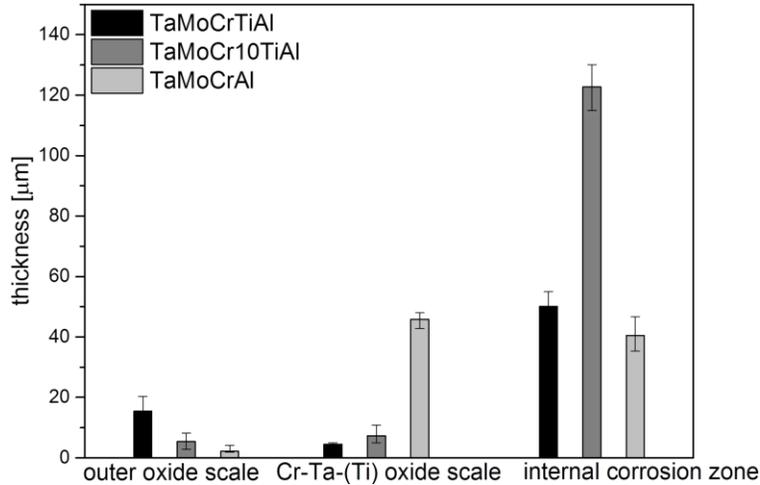
245  
 246 **Fig. 5.** Macroscopic images of oxidized samples after exposure to air at 1200 °C for 24 h: a. TaMoCrTiAl, b. TaMoCr10TiAl, c.  
 247 TaMoCrAl.  
 248



249  
 250 **Fig. 6.** BSE-SEM images of investigated alloys after exposure to air at 1200 °C for 24 h. Detail image of the dashed frame in b. is  
 251 presented in Fig S. 3. In addition, detailed images of the outer oxide layers of b. and c. are given in Fig. 2 and Fig. 3.

252 Fig. 7 quantitatively represents the measured thicknesses of the outer oxide layer, the rutile Cr-Ta-(Ti) oxide layer at  
 253 the oxide/substrate interface and the underlying internal corrosion zone. The outer oxide layer consists of  $\text{Cr}_2\text{O}_3$ ,  
 254  $\text{Al}_2\text{O}_3$  and  $\text{TiO}_2$  for TaMoCrTiAl as well as TaMoCr10TiAl and  $\text{Cr}_2\text{O}_3$ ,  $\text{Al}_2\text{O}_3$  for TaMoCrAl. The thickness of the  
 255 rutile Cr-Ta-(Ti) oxide scale increases with reduced Ti content. In the case of the Ti-free alloy, the rutile Cr-Ta oxide  
 256 scale is more pronounced in comparison to the zone of internal corrosion. The alloy with 10 at.%Ti yields the  
 257 thickest zone of internal corrosion, while the Ti-free alloy possesses the thinnest one.

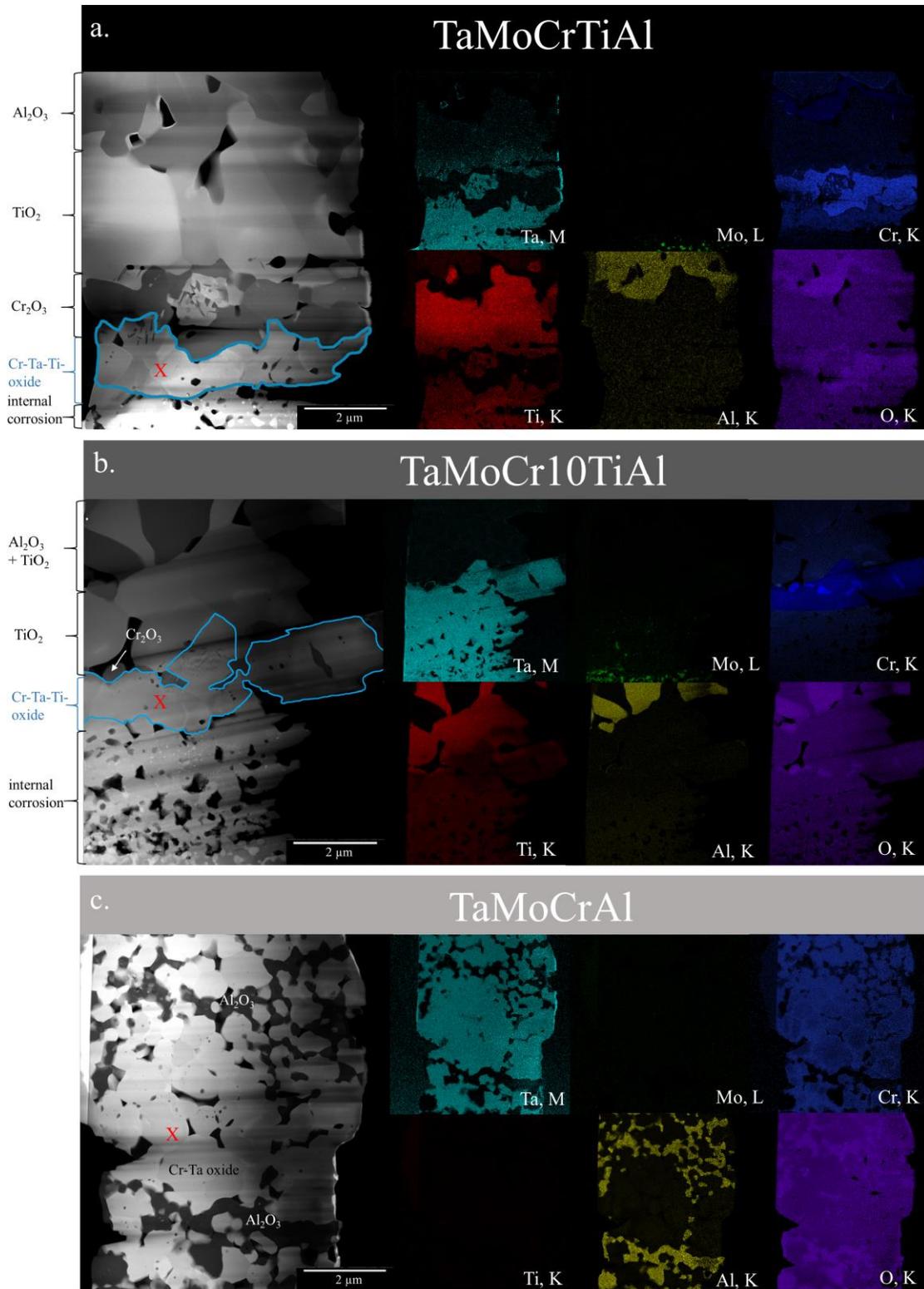
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**Fig. 7** Thicknesses of outer oxide scale, Cr-Ta-(Ti) oxide scale and internal corrosion zone on investigated alloys after oxidation at 1200 °C for 24 h.

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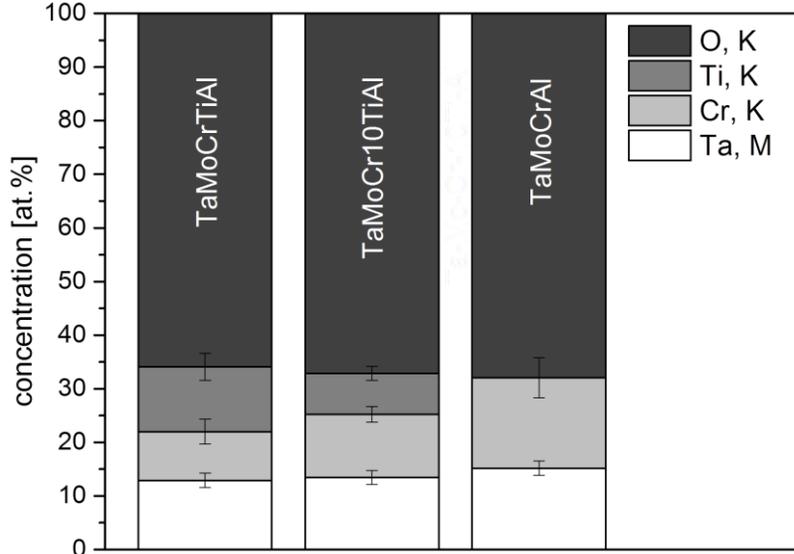
To investigate the rutile Cr-Ta-(Ti) oxide scales in more detail, site-specific TEM lamellae were extracted from the oxidized samples. In Fig. 8 HAADF-STEM images are depicted together with the corresponding chemical maps by STEM. Furthermore, the "X-marks" indicate the locations where EELS spectra (Fig. 10.) were recorded for detailed chemical-bond analyses. Below the  $TiO_2$  scales, a network of  $Cr_2O_3$  particles is visible in the TaMoCrTiAl (Fig. 8 a.). In the scale of TaMoCr10TiAl, however, only a few isolated  $Cr_2O_3$  particles with an average diameter of approximately 400 nm are detected (Fig. 7 b.). Above the metallic substrate, the rutile Cr-Ta-(Ti) oxide scales (highlighted by blue frames) consisting of the elements Ta, Ti, Cr and O are identified on both alloys with Ti. The FIB lamella of TaMoCrAl alloy was extracted from the centre of the rutile Cr-Ta oxide scale because the alloy forms a thick oxide layer. In Fig. 8 c., a mixture of rutile Cr-Ta oxides and  $Al_2O_3$  particles is observed. In addition, the STEM-EDX mappings prove the absence of Mo in the oxide layers.



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**Fig. 8** HAADF-STEM micrographs with corresponding EDX mappings of extracted TEM lamellae from rutile Cr-Ta-(Ti) oxide scales of the investigated alloys after oxidation to air at 1200 °C for 24 h: a. TaMoCrTiAl, b. TaMoCr10TiAl and c. TaMoCrAl. “X” marks the location of the EELS records. Micrographs a. of TaMoCrTiAl taken from [47].

280 The STEM-EDX results were quantified to determine the relative metal concentrations in the formed rutile Cr-Ta-  
 281 (Ti) oxides (Fig. 9). All oxides, regardless of the Ti content in the alloys, correspond to a  $MeO_2$  stoichiometry.  
 282 However, the ratio of the metallic elements  $Me = Ti, Ta$  and  $Cr$  in the formed rutile Cr-Ta-(Ti) oxides varies. A  
 283 higher amount of Ti and a lower concentration of Cr were measured in rutile Cr-Ta-Ti oxide formed on  
 284 TaMoCrTiAl. The opposite observations were made in the case of the alloy with 10 % Ti. In rutile Cr-Ta oxide on  
 285 TaMoCrAl, equal amounts of Cr and Ta were found.  
 286



287 **Fig. 9** Element distribution [at. %] in the rutile Cr-Ta-(Ti) oxides of the TEM lamellae in Fig. 8 (blue frame in a. and b., Al  
 288 depleted region in c). The elemental distribution was determined from the STEM-EDX mappings by quantification of integrated  
 289 spectral intensities from homogeneous regions of the Cr-Ta-(Ti) oxides.  
 290

291 In literature, the following chemical reaction for the formation of  $CrTaO_4$  corresponding to a solid solution oxide of  
 292 the stoichiometry  $2(Cr,Ta)O_2$  with Cr, Ta evenly distributed of the cation sites of rutile crystal structure is known  
 293 [45,66–68]:  
 294  
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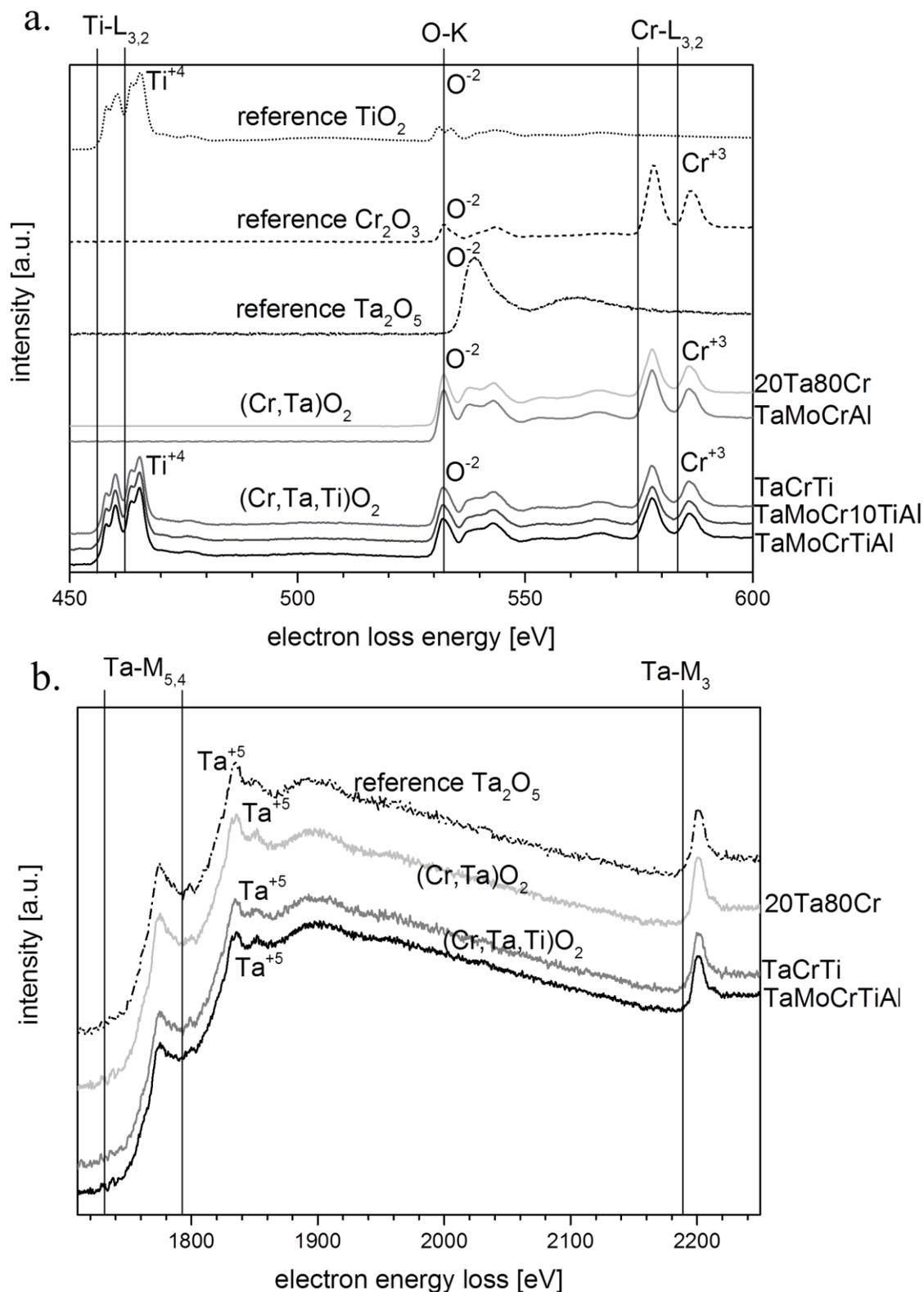


296 The formation of the Ti-containing  $CrTaTiO_6$  corresponding to a solid solution  $3(Cr,Ta,Ti)O_2$  oxides was postulated  
 297 as follows [69]:  
 298



299 Assuming charge neutrality of the compounds and an unequivocal oxidation of  $O^{2-}$ , the following oxidation states of  
 300 the metallic elements in the oxides of equations (1) & (2) are obtained:  $Cr^{3+}$ ,  $Ta^{5+}$ , and  $Ti^{4+}$ . To verify this  
 301 postulation, the EELS near-edge structures of the L/Mionization edges of the different cations were analyzed, which  
 302 reflect the respective oxidation states in terms of the edge shape and onset. Specifically, spectra of the L edges of Ti  
 303 and Cr, the O-K edge and the Ta-M edge of the rutile Ta-Cr-(Ti) oxides, formed on the different alloys, were  
 304 recorded on the respective TEM lamellae at the positions as labeled in Fig. 8 and Fig S. 7. The oxidation states of the  
 305 formed rutile Cr-Ta-(Ti) oxides on the RHEAs were identified by comparison with reference spectra of pure  $TiO_2$ ,  
 306  $Cr_2O_3$  and  $Ta_2O_5$  reference particles (cf. equations (1) and (2)). In addition, EELS of the formed oxides on the  
 307 additional alloys 20Ta80Cr ( $CrTaO_4$  former) and TaCrTi ( $CrTaTiO_6$  former) was performed. The extraction  
 308 locations of the TEM lamellae of the formed rutile Cr-Ta-(Ti) oxides on the additional alloys are displayed in Fig S.  
 309 6. Fig S. 7 represents the TEM lamellae of those oxides. The identity of the reference materials was verified by XRD  
 310 patterns and HAADF-STEM images which are given in supplementary material (Fig S. 8 and Fig S. 9). All EELS  
 311 spectra are summarized in Fig. 10.  
 312

313 In terms of both, the shape of the edges as well as their onset energy, all metal edges are in excellent agreement with  
314 their respective references and verify the oxidation states initially derived from (1) and (2), i.e. the rutile  
315  $(\text{Cr,Ta,(Ti)})\text{O}_2$  oxides consist of  $\text{Ta}^{5+}$ ,  $\text{Cr}^{3+}$  and  $\text{Ti}^{4+}$ . For all oxides containing Ti (rutile  $(\text{Cr,Ta,Ti})\text{O}_2$  oxides) and the  
316  $\text{TiO}_2$  references the Ti-L<sub>3</sub> and Ti-L<sub>2</sub> edges are observed at 456 eV and 462 eV, respectively. The two edges show  
317 double-peak shape at the same energy loss, which is typical of  $\text{Ti}^{4+}$  coordinated by  $\text{O}^{2-}$  [59]. Similarly, the Cr-L<sub>3</sub> and  
318 Cr-L<sub>2</sub> edges of all Cr containing oxides rutile  $(\text{Cr,Ta,(Ti)})\text{O}_2$  oxides and the  $\text{Cr}_2\text{O}_3$  reference are observed at 575 eV  
319 and 584 eV, respectively [70]. As for the Ti and Cr, the Ta-M edges in the EELS of the oxides rutile  $(\text{Cr,Ta,(Ti)})\text{O}_2$   
320 oxides and the  $\text{Ta}_2\text{O}_5$  reference are remarkably similar as the shape of the edges are nearly identical and the  
321 individual edges appear at the same energies (1735 eV, 1793 eV and 2194 eV for the Ta-M<sub>5</sub>, Ta-M<sub>4</sub> and Ta-M<sub>3</sub> edge,  
322 respectively) [71]. The O-K edge cannot directly be compared to the reference spectra as the O-K edge (532 eV) is  
323 very sensitive to the metal cations in the coordination sphere of each  $\text{O}^{2-}$  anion.



324  
 325 **Fig. 10** a. EEL spectra of the energy-loss range 450 - 600 eV (Ti-L, O-K, Cr-L edges) of the reference materials TiO<sub>2</sub>, Cr<sub>2</sub>O<sub>3</sub> and  
 326 Ta<sub>2</sub>O<sub>5</sub> in dotted lines and the formed oxides on the investigated alloys presented in Figure 8. b. Ta-M edges (energy-loss range  
 327 1700 - 2250 eV) of the reference material Ta<sub>2</sub>O<sub>5</sub>, the rutile (Cr,Ta)O<sub>2</sub> of the additional alloy 20Ta80Cr, as well as the rutile  
 328 (Cr,Ta,Ti)O<sub>2</sub> of the additional alloy TaCrTi and TaMoCrTiAl. The spectra of the Ta-M edges are identical for the rutile (Cr,Ta)O<sub>2</sub>  
 329 of TaMoCrAl and rutile (Cr,Ta,Ti)O<sub>2</sub> TaMoCr10TiAl and not shown here.

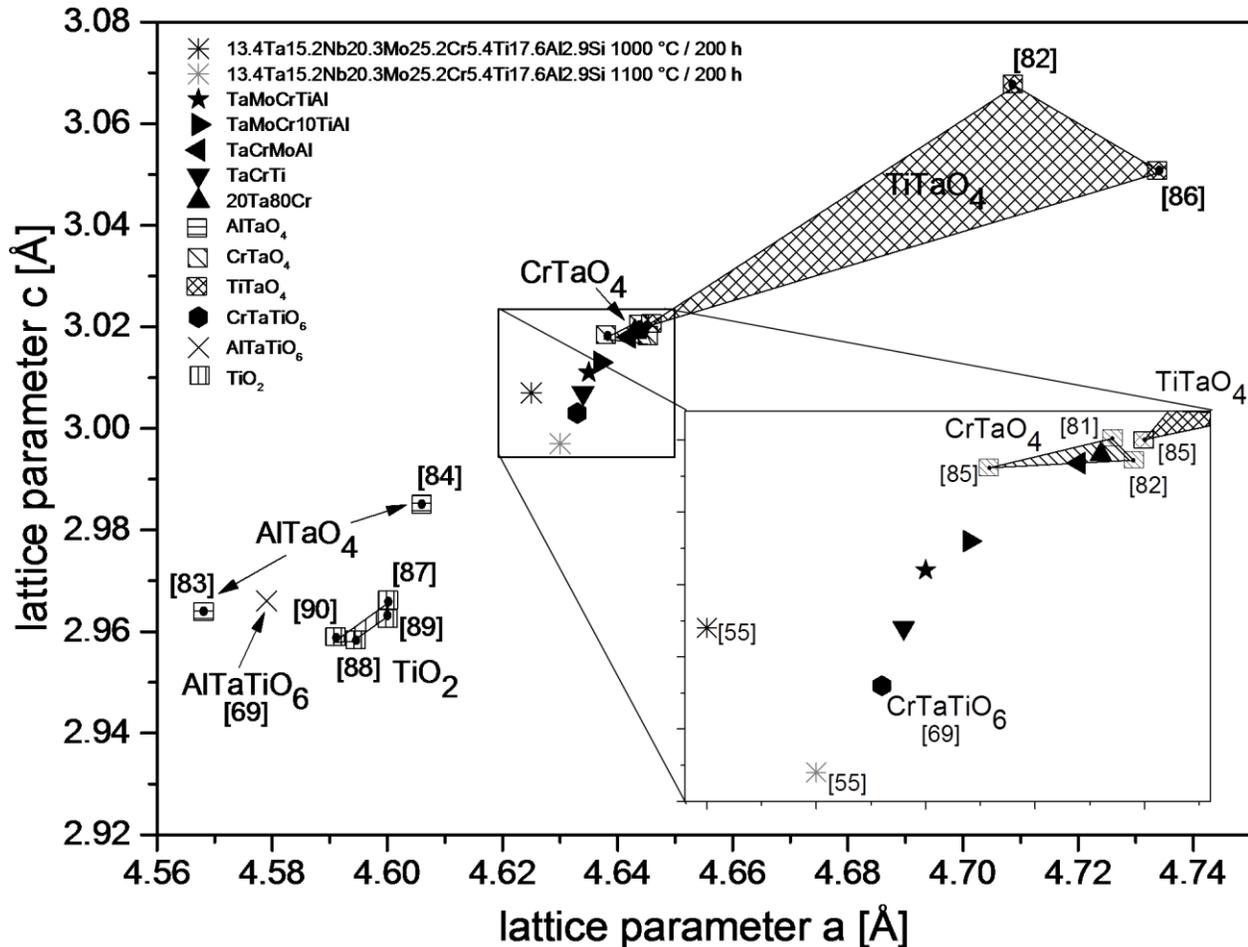
#### 4. Discussion

Compared to the Ti-containing rutile (Cr,Ta,Ti)O<sub>2</sub> forming alloys, the TaMoCrAl reveals a significantly thicker and porous oxide layer. In preliminary studies, Müller et al. [45] postulated that the higher Mo content in TaMoCrAl and the higher content of non-oxidation-resistant A15 phase (Mo<sub>3</sub>Al) [72] of this alloy dramatically deteriorate the oxidation behaviour at 1000 °C. Mo is well-known to create volatile MoO<sub>3</sub> above 800 °C [25,73,74]. This gaseous oxide evolves also during the oxidation of the A15 phase and results in pores, which create new surfaces and further accelerate the oxidation and evaporation of Mo [45]. Furthermore, the authors reported the formation of Ta<sub>2</sub>O<sub>5</sub> in the oxide layer that causes growth stresses leading to the formation of cracks and partial flaking of the oxide layer [45]. The oxidation behaviour of this alloy at 1200 °C is similar to that observed at 1000 °C [22]. A negative mass change was detected (Fig. 3). The porous oxide scale consists of a mixture of Al<sub>2</sub>O<sub>3</sub> particles and rutile (Cr,Ta)O<sub>2</sub> after oxidation at 1200 °C for 24 h. The chemical compositions as well as the morphology of the two regions in the TEM lamella indicate that the Cr<sub>2</sub>Ta Laves phase forms rutile (Cr,Ta)O<sub>2</sub> whereas the Al<sub>2</sub>O<sub>3</sub> particles originate from the oxidized A15 phase.

The experimental results in this study reveal that the chemical nature of the rutile (Cr,Ta,Ti)O<sub>2</sub> changes with varying Ti content in the alloy system. The characteristics of these complex rutile oxides differ enormously. For example, Li et al. [75] found that the compact Al<sub>2</sub>O<sub>3</sub> on the surface of the alloy Ta-10W-6Al (wt.%) is consumed during oxidation at 1000 °C (4 h) as a result of rutile AlTaO<sub>4</sub> scale formation and, consequently, a mesh-type structure is formed, which does not effectively protect the substrate. In line with this finding, Mitsui et al. [76] observed the formation of a thick oxide layer consisting of a mixture of α-Al<sub>2</sub>O<sub>3</sub>, β-Ta<sub>2</sub>O<sub>5</sub> and rutile AlTaO<sub>4</sub> after oxidation of the sputter-deposited Al-80Ta (at. %) alloy at 900 °C (p<sub>O2</sub>=20 kPa) for 20 h. A positive effect of rutile TiTaO<sub>4</sub> on chromium oxide forming Ni-based superalloys is reported by Jalowicka et al. [77]. They demonstrated that the formation of rutile TiTaO<sub>4</sub> particles prevents the incorporation of Ti into the protective Cr<sub>2</sub>O<sub>3</sub> scale and, thus, enhances the oxidation resistance of Ni-based superalloy PWA1483 as well as various Ta- and Ti-containing model alloys in synthetic air at 1050 °C up to 500 h. Comparing the oxidation behaviour of Rene 80 and IN 792 at 1050 °C in Ar-20 % O<sub>2</sub> up to 50 h, Nowak et al. [78] concluded that the formation of rutile TiTaO<sub>4</sub> prevents the Ti flux to the outer interface and reduces the oxidation kinetics. It should be noted that rutile TaTiO<sub>4</sub> forms underneath the protective scale and only serves as a barrier for Ti outward diffusion. In contrast to rutile TaTiO<sub>4</sub>, a clear protective effect of continuous rutile CrTaO<sub>4</sub> layers at the substrate/oxide interface on nickel-based superalloys is reported [66,79,80]. Ren et al. observed that the continuous rutile CrTaO<sub>4</sub> layer inhibits the outward diffusion of cations on the one hand and reduces the inward diffusion of oxygen on the other hand on a directionally-solidified nickel-based superalloy with 5.0 wt. % Ta during oxidation at temperatures between 850 and 900 °C for up to 300 h [66]. Lo et al. also reported such a protective effect of rutile CrTaO<sub>4</sub> on the RHEA 13.4Ta15.2Nb20.3Mo25.2Cr5.4Ti17.6Al2.9Si (at. %), during oxidation at 1000 °C and 1100 °C for 200 h [55]. The EDX measurements in this study revealed that there are considerable amounts of other elements dissolved in the rutile CrTaO<sub>4</sub> (7 at.% Al, 0.2 at.% Si, 3.9 at.% Ti, 6.3 at.% Nb, and 2.8 at.% Mo), which explain the different lattice parameters compared to pure rutile CrTaO<sub>4</sub>. Mani et al. published the lattice parameters in addition to the electrical properties of rutile AlTaTiO<sub>6</sub> and rutile CrTaTiO<sub>6</sub> [69,81]. Peterson et al. and Mani et al. pointed out that rutile CrTaTiO<sub>6</sub> undergoes cell distortion towards higher lattice parameters compared to rutile TiO<sub>2</sub> due to the larger average interatomic distances between the cations as well as the cations and anions as a result of the different ionic radii [69,81,82]. However, the axial ratios are similar to those of rutile TiO<sub>2</sub> [69,81]. About comprehensive study on the protective properties of complex rutile oxides based on Ta, Ti (and Cr) at high temperatures is not reported in literature.

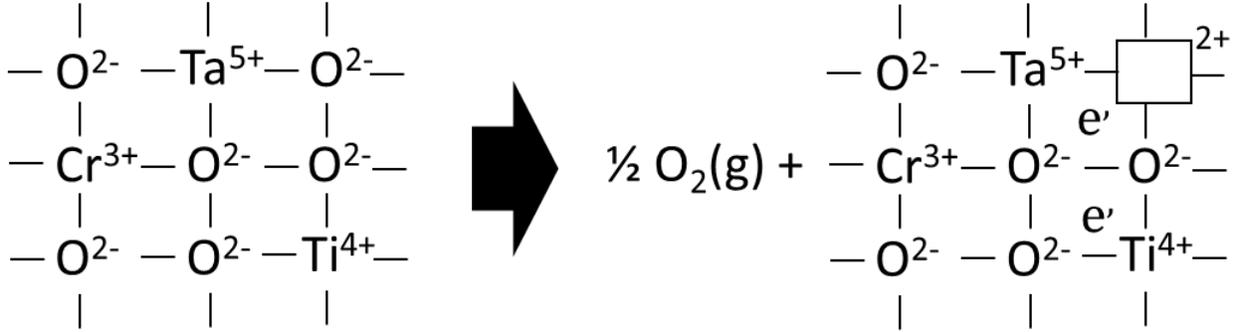
In Fig. 11, literature data on lattice parameters of various complex rutile oxides (AlTaO<sub>4</sub> [83,84], AlTaTiO<sub>6</sub> [69], CrTaO<sub>4</sub> [81,82,85], CrTaTiO<sub>6</sub> [69], TaTiO<sub>4</sub> [82,85,86]) and rutile TiO<sub>2</sub> [87–90] are compared with the determined lattice parameters of the formed rutile (Cr,Ta,Ti)O<sub>2</sub> on the investigated alloys (see Table 2). Additionally, lattice parameters of the rutile CrTaO<sub>4</sub> formed on RHEA 13.4Ta15.2Nb20.3Mo25.2Cr5.4Ti17.6Al2.9Si (in at. %) during oxidation at 1000 °C and 1100 °C for 200h are also included [26]. The determined lattice parameters of the rutile (Cr,Ta)O<sub>2</sub> formed on TaMoCrAl (a = 4.642 Å, c = 3.018 Å) and the additional alloy 20Ta80Cr (a = 4.643 Å, c = 3.019 Å) are similar to those reported in literature for rutile CrTaO<sub>4</sub> [81,82,85,91]. In addition to the similarity in lattice parameters, the local compositions as derived from STEM-EDX (Fig. 9 and Fig. 10) are in agreement with the chemical composition of the formed rutile (Cr,Ta)O<sub>2</sub>. The determined lattice parameters of rutile (Cr,Ta,Ti)O<sub>2</sub> grown on the TaMoCrTiAl (a = 4.635 Å, c = 3.011 Å) [47] are elongated in both, a and c direction compared to rutile CrTaTiO<sub>6</sub> (a = 4.633 Å, c = 3.003 Å) by 0.04 % and 0.27 %, respectively. Thus, they lie between the parameters of rutile CrTaO<sub>4</sub> and rutile CrTaTiO<sub>6</sub> [69,81,82,85,91]. The lattice parameters of the formed rutile (Cr,Ta,Ti)O<sub>2</sub> on

386 TaMoCr10TiAl and TaCrTi are close to those of the oxide grown on TaMoCrTiAl (Fig. 11). Combining the  
 387 knowledge about the lattice parameters and the TEM-EELS results (Fig. 10) it is concluded that the type rutile  
 388 (Cr,Ta,Ti)O<sub>2</sub> forms on TaCrTi, TaMoCr10TiAl and TaMoCrTiAl. The lattice parameters of the rutile (Cr,Ta,Ti)O<sub>2</sub>  
 389 formed on TaCrTi are slightly shifted towards rutile CrTaTiO<sub>6</sub>, whereas the lattice parameters of the rutile  
 390 (Cr,Ta,Ti)O<sub>2</sub> of the alloy TaMoCr10TiAl are slightly stretched towards rutile CrTaO<sub>4</sub> compared to the parameters of  
 391 rutile (Cr,Ta,Ti)O<sub>2</sub> grown on TaMoCrTiAl. It should be noted in this context that only a single lattice parameter  
 392 dataset of rutile CrTaTiO<sub>6</sub> exists in literature. The increased lattice parameter of rutile (Cr,Ta,Ti)O<sub>2</sub> formed on  
 393 TaMoCr10TiAl compared to that of TaMoCrTiAl could be explained by the slightly higher Ta content and the  
 394 depletion of the element Ti with the smallest ionic radius in the non-stoichiometric rutile (Cr,Ta,Ti)O<sub>2</sub> (Fig. 9). This  
 395 presumption is supported by the larger lattice parameter of the rutile (Cr,Ta)O<sub>2</sub> of TaMoCrAl with an even higher Ta  
 396 content (cf. Fig. 9).  
 397



398 **Fig. 11** Literature data on lattice parameters of various complex rutile oxides (AlTaO<sub>4</sub>, AlTaTiO<sub>6</sub>, CrTaO<sub>4</sub>, CrTaTiO<sub>6</sub>, TaTiO<sub>4</sub>)  
 399 and lattice parameters of rutile (Cr,Ta,(Ti))O<sub>2</sub> formed on the alloys (TaMoCrTiAl, TaMoCr10TiAl, TaMoCrAl, 20Cr80Cr,  
 400 TaCrTi) after 24 h oxidation at 1200 °C in air. In addition, lattice parameters of rutile CrTaO<sub>4</sub> oxide on RHEA  
 401 13.4Ta15.2Nb20.3Mo25.2Cr5.4Ti17.6Al2.9Si (at. %) after oxidation to air at 1000 °C and 1100 °C for 200 h are given.  
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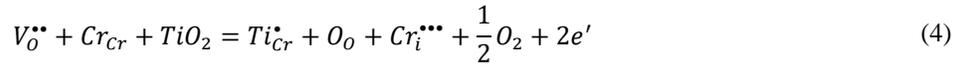
404 Previous studies revealed that the protective rutile (Cr,Ta,Ti)O<sub>2</sub> formed on the TaMoCrTiAl alloy grows in a  
 405 parabolic manner inwards at the metal-oxide interface due to oxygen diffusion. [45,47]. The valence states according  
 406 to the TEM-EELS results (Fig. 10) of an idealized rutile (Cr,Ta,Ti)O<sub>2</sub> are Cr<sup>3+</sup>, Ti<sup>4+</sup>, Ta<sup>5+</sup> with an oxidation state of O  
 407 of 2-. As EELS indicates, no significant concentrations of metal ions of differing oxidation states were observed. Fig.  
 408 12 illustrates the hypothetically ideal lattice of rutile (Cr,Ta,Ti)O<sub>2</sub> and the possible oxygen vacancy formation with  
 409 the corresponding defect formula (equation (3)). As equation 3 illustrates, it is assumed that the rutile (Cr,Ta,Ti)O<sub>2</sub>  
 410 grows by oxygen diffusion through vacancies in the anion sublattice.



411  
412 **Fig. 12** Ideal atomic lattice of rutile (Cr,Ta,Ti)O<sub>2</sub> and formation of a vacancy in a n-type semi-conductor oxide.



413  
414 The chemical analysis in Fig. 9 discloses a non-equimolar ratio of the cations (Cr, Ta, Ti) in the formed (Cr,Ta,Ti)O<sub>2</sub>  
415 on the alloys with different Ti contents (TaMoCrTiAl and TaMoCr10TiAl). Apparently, the Ta contents are nearly  
416 the same indicating that Ti tends to occupy the Cr sites. The following defect equation is formulated:  
417



418  
419 Classical oxidation theory states that occupation of cation sites by higher valence cations causes a decreased  
420 concentration of  $V_{\text{O}}^{\bullet\bullet}$  in n-type conducting oxides and results in a reduced growth rate of the oxide. By comparing the  
421 resulting oxide layers on TaMoCr10TiAl and TaMoCrTiAl, a positive impact on the oxidation behaviour with  
422 increasing Ti content is revealed, which can be attributed to the replacement of Cr<sup>3+</sup> by Ti<sup>4+</sup> on the cationic sublattice.  
423 The following experimental results support the assumption of defect equation (4): (i) According to equation (4), the  
424 occupation of Cr<sup>3+</sup> cation lattice sites by Ti<sup>4+</sup> reduces the vacancy concentration in the oxide, which implies a thinner  
425 and less permeable rutile (Cr,Ta,Ti)O<sub>2</sub> scale. As shown in Fig. 7, the alloy with a higher Ti content (TaMoCrTiAl)  
426 forms a thinner rutile (Cr,Ta,Ti)O<sub>2</sub> layer and less pronounced zone of internal corrosion with Al<sub>2</sub>O<sub>3</sub> and TiN  
427 precipitates in comparison to TaMoCr10TiAl. (ii) Equation (4) discloses that, if Ti<sup>4+</sup> cations occupy Cr<sup>3+</sup> cation  
428 lattice sites, Cr must adopt interstitial lattice sites. The interstitial Cr can further diffuse outwards and react with O<sup>2-</sup>  
429 to Cr<sub>2</sub>O<sub>3</sub>. As a consequence, the rutile (Cr,Ta,Ti)O<sub>2</sub> would become Cr-depleted and more Cr<sub>2</sub>O<sub>3</sub> particles would be  
430 formed in the vicinity of (Cr,Ta,Ti)O<sub>2</sub>. The EDX analysis reveals (Fig. 9), on the one hand, a higher Ti content and,  
431 on the other hand, a reduced Cr content in the formed rutile (Cr,Ta,Ti)O<sub>2</sub> on TaMoCrTiAl as compared to  
432 TaMoCr10TiAl. Moreover, the higher content of released Cr in TaMoCrTiAl seems to react with oxygen forming a  
433 nearly continuous chromia scale (see Fig. 8. a.), while only a few chromia particles were found above the  
434 (Cr,Ta,Ti)O<sub>2</sub> scale (see Fig. 8. b.).

435 Finally, the free standard enthalpies of formation  $\Delta G$  of the relevant oxides in the Ta-Mo-Cr-Ti-Al system were  
436 calculated at 1200 °C using the software FactSage. The calculations of  $\Delta G$  of the complex rutile oxides are based on  
437 the chemical reactions given in equations (1) and (2) and are as follows:

$$\Delta G_{\text{CrTaO}_4}^0 = \frac{1}{2}(\Delta G_{\text{Cr}_2\text{O}_3}^0 + \Delta G_{\text{Ta}_2\text{O}_5}^0) \quad (5)$$

$$\Delta G_{\text{CrTaTiO}_6}^0 = \frac{1}{2}(\Delta G_{\text{Cr}_2\text{O}_3}^0 + \Delta G_{\text{Ta}_2\text{O}_5}^0) + \Delta G_{\text{TiO}_2}^0 \quad (6)$$

438  
439 The calculated free standard enthalpies of formation of the relevant oxides are displayed in Fig. 13. From a  
440 thermodynamic point of view, a chemical reaction as described in equation (2) to CrTaTiO<sub>6</sub> (corresponds to  
441 (Cr,Ta,Ti)O<sub>2</sub>) involving the oxide TiO<sub>2</sub>, which has a lower standard free enthalpy of formation (-676 kJ / mol O<sub>2</sub>)  
442 compared to the oxide CrTaO<sub>4</sub> (corresponds to (Cr,Ta)O<sub>2</sub>) (-535 kJ / mol O<sub>2</sub>), results in a higher thermodynamic  
443 driving force of formation (-606 kJ / mol O<sub>2</sub>). The high thermodynamic stability of CrTaTiO<sub>6</sub> (i.e. higher than that of  
444 chromia) in addition to the low growth rate (i.e. lower than that of chromia [58]) reveal attractive protective  
445 properties. It should, however, be stressed that similar to chromia CrTaTiO<sub>6</sub> suffers from high diffusion rates of  
446 oxygen and nitrogen resulting in thick zones of internal corrosion (see Fig. 6).  
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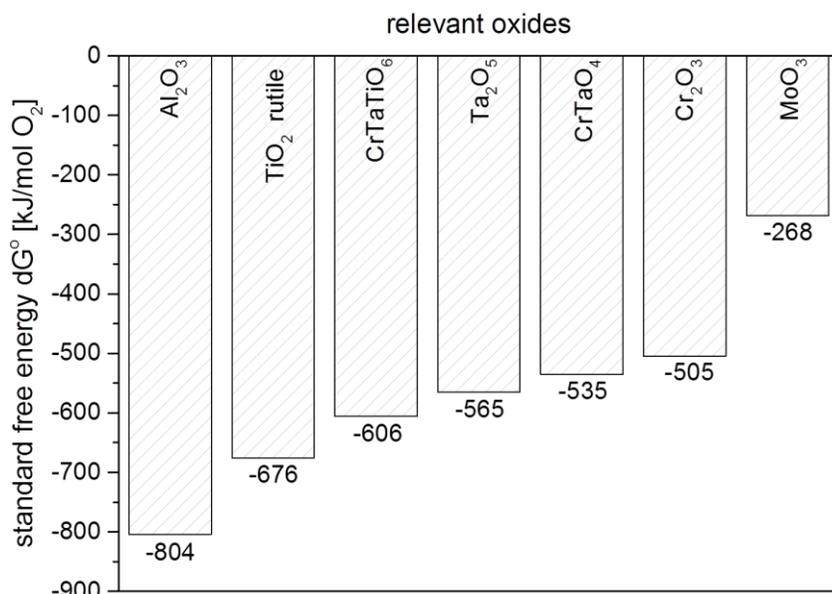


Fig. 13 Calculated standard free energy of formation of relevant oxides at 1200 °C.

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## 451 5. Conclusions

452  
453 Rutile (Cr,Ta,Ti)O<sub>2</sub> with a non-stoichiometric ratio of metallic elements Me = Ti, Ta and Cr form on RHEAs in Ta-  
454 Mo-Cr-Ti-Al system during oxidation at 1200°C. The experimental results lead to the conclusion that the metallic  
455 elements have oxidation states Cr<sup>3+</sup>, Ti<sup>4+</sup>, Ta<sup>5+</sup> in the rutile (Cr,Ta,Ti)O<sub>2</sub> oxide formed on equiatomic TaMoCrTiAl  
456 and TaMoCr10TiAl. The enhanced Ti concentration in (Cr,Ta,Ti)O<sub>2</sub> reduces the oxygen permeability improving the  
457 diffusion properties. Cations Ti<sup>4+</sup> appear to occupy Cr<sup>3+</sup> lattice sites leading to reduced oxygen vacancy  
458 concentration and consequently thinner oxide scales and zones of internal corrosion. (Cr,Ta,Ti)O<sub>2</sub> reveals  
459 perspective protective properties as it possesses higher thermodynamic stability as well as lower growth rates  
460 compared to widely accepted chromia scales.

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462  
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466 1, DFG INST 221/126-1) and sample preparation equipment.  
467

## 468 Author contributions

469  
470 **Steven Schellert:** Writing - Original Draft, Validation, Investigation, Visualization  
471 **Bronislava Gorr:** Conceptualization, Visualization, Supervision, Project administration, Formal analysis, Funding  
472 acquisition, Writing – Review & Editing  
473 **Mathias Galetz:** Conceptualization, Formal analysis, Writing – Review & Editing, Visualization, Formal analysis  
474 **Christian Wiktor:** Investigation, Resources, Visualization, Writing – Review & Editing  
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476 **Matthias Weber:** Visualization, Investigation,  
477 **Alexander Kauffmann:** Formal analysis, Resources, Visualization, Writing – Review & Editing  
478 **Martin Heilmaier:** Conceptualization, Resources, Funding acquisition, Writing – Review & Editing  
479 **Hans-Jürgen Christ:** Conceptualization, Resources, Writing – Review & Editing, Formal analysis  
480 **Benjamin Butz:** Investigation, Resources, Visualization, Writing – Review & Editing  
481

482 **Data availability**

483  
484 The data that support the finding of this study are available as supplementary materials or from the corresponding  
485 author upon reasonable request.  
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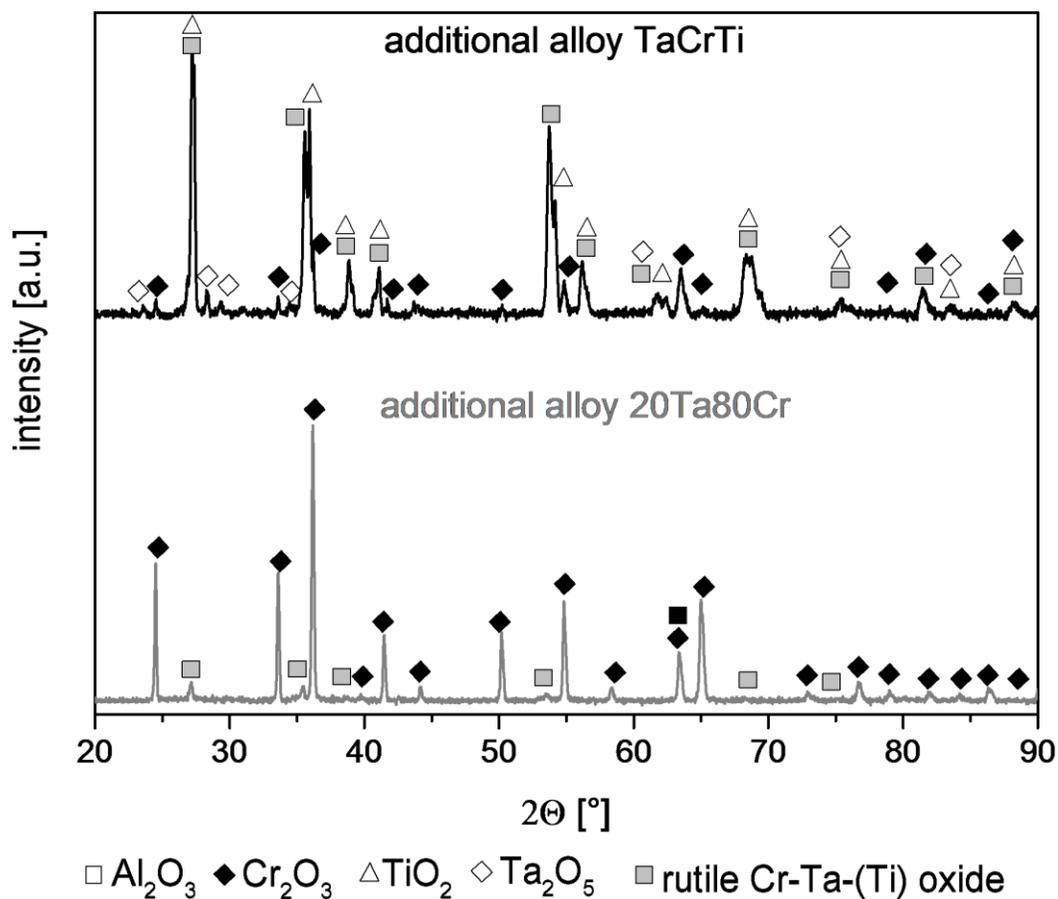
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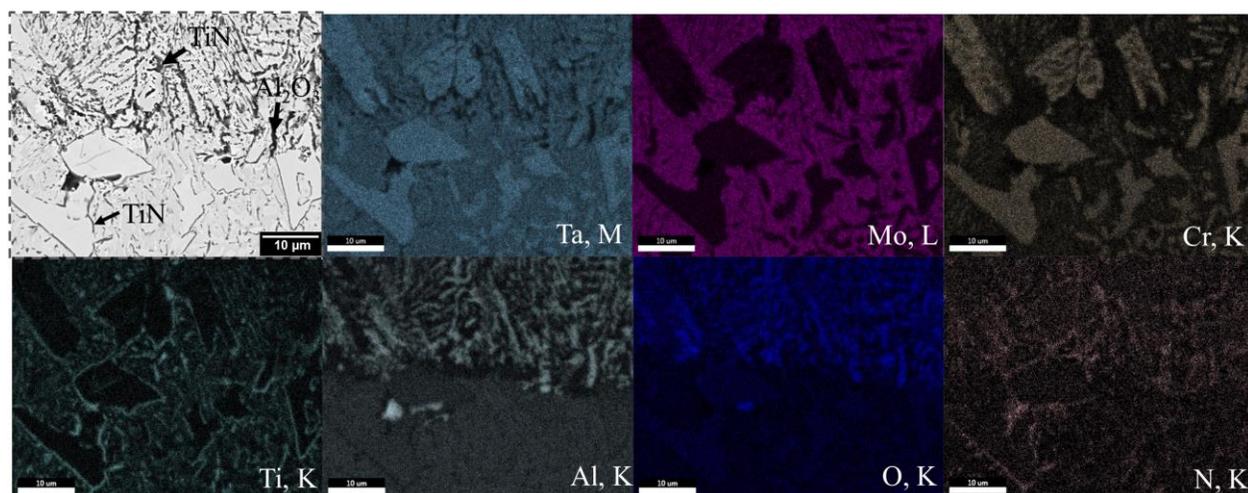
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730 Supplementary Material

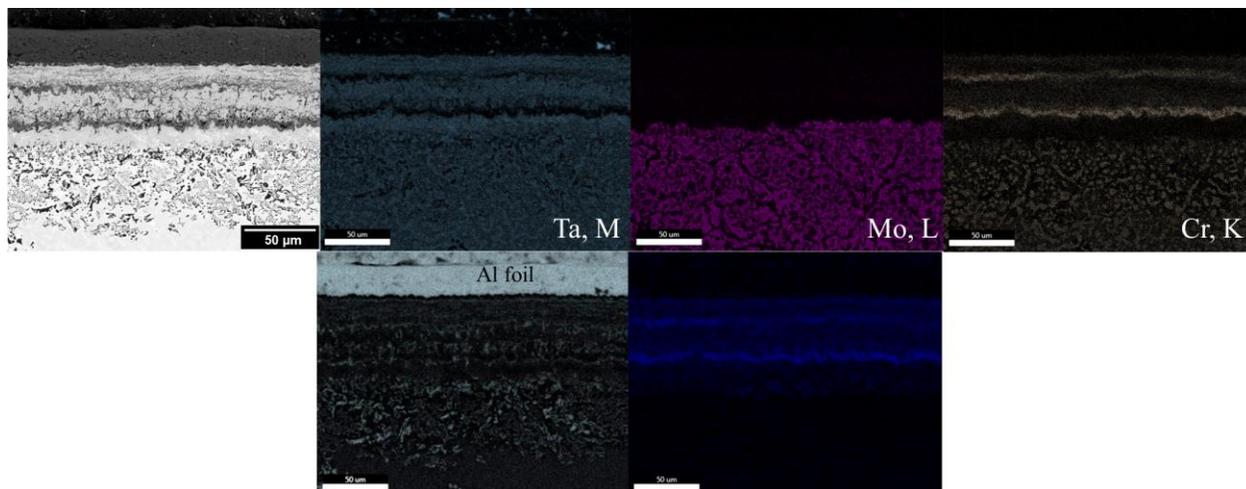
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733 **Fig S. 1** XRD pattern of additional alloys 20Ta80Cr and TaCrTi after oxidation to air at 1200 °C for 24 h. The peaks are labeled  
734 according to simulated XRD data based on the structures of the oxides listed in the legend.  
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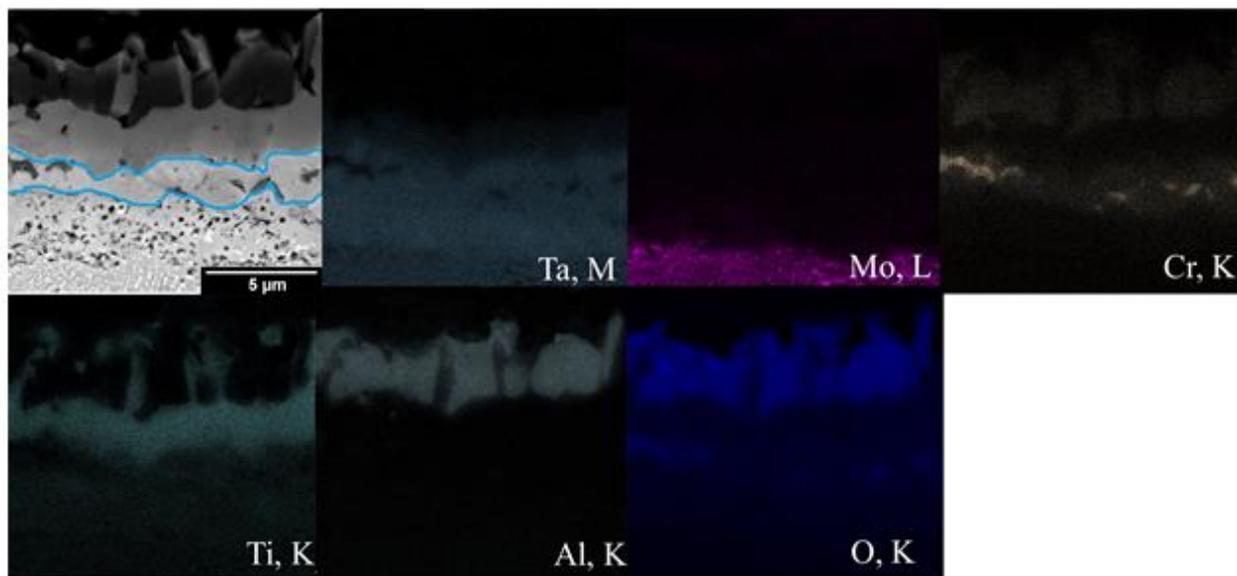
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737 **Fig S. 2** BSE-SEM image of details of the internal corrosion zone in TaMoCr10TiAl (marked area in Fig. 6 b. after exposure to  
738 air at 1200 °C for 24 h and the corresponding EDX-mapping.  
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741 **Fig S. 3** BSE-SEM micrograph of oxide scale formed on TaMoCrAl after exposure to air at 1200 °C for 24 h and the  
 742 corresponding EDX-mapping.

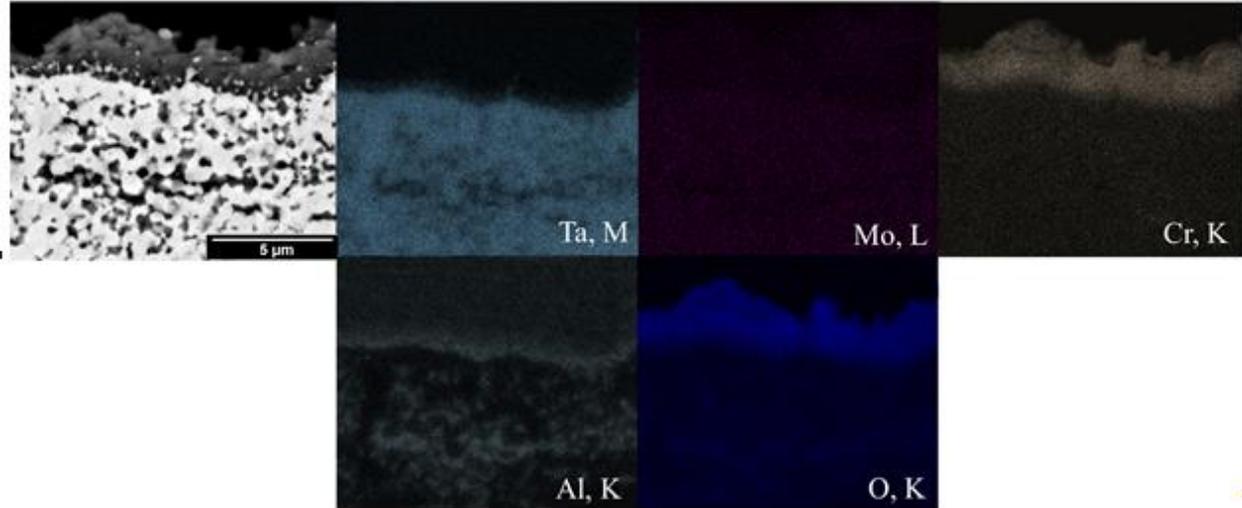
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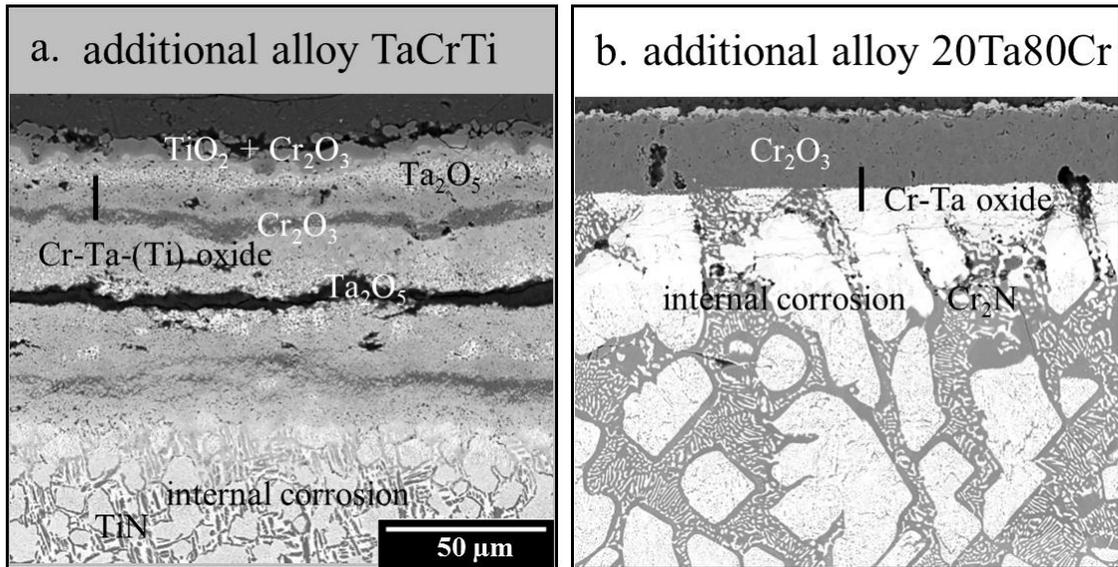
744 **Fig S. 4** BSE-SEM micrograph of outer oxide scale formed on TaMoCr10TiAl after exposure to air at 1200 °C for 24 h and the  
 745 corresponding EDX-mapping. The (Cr,Ta,Ti)O<sub>2</sub> scale is highlighted in the BSE-SEM image.  
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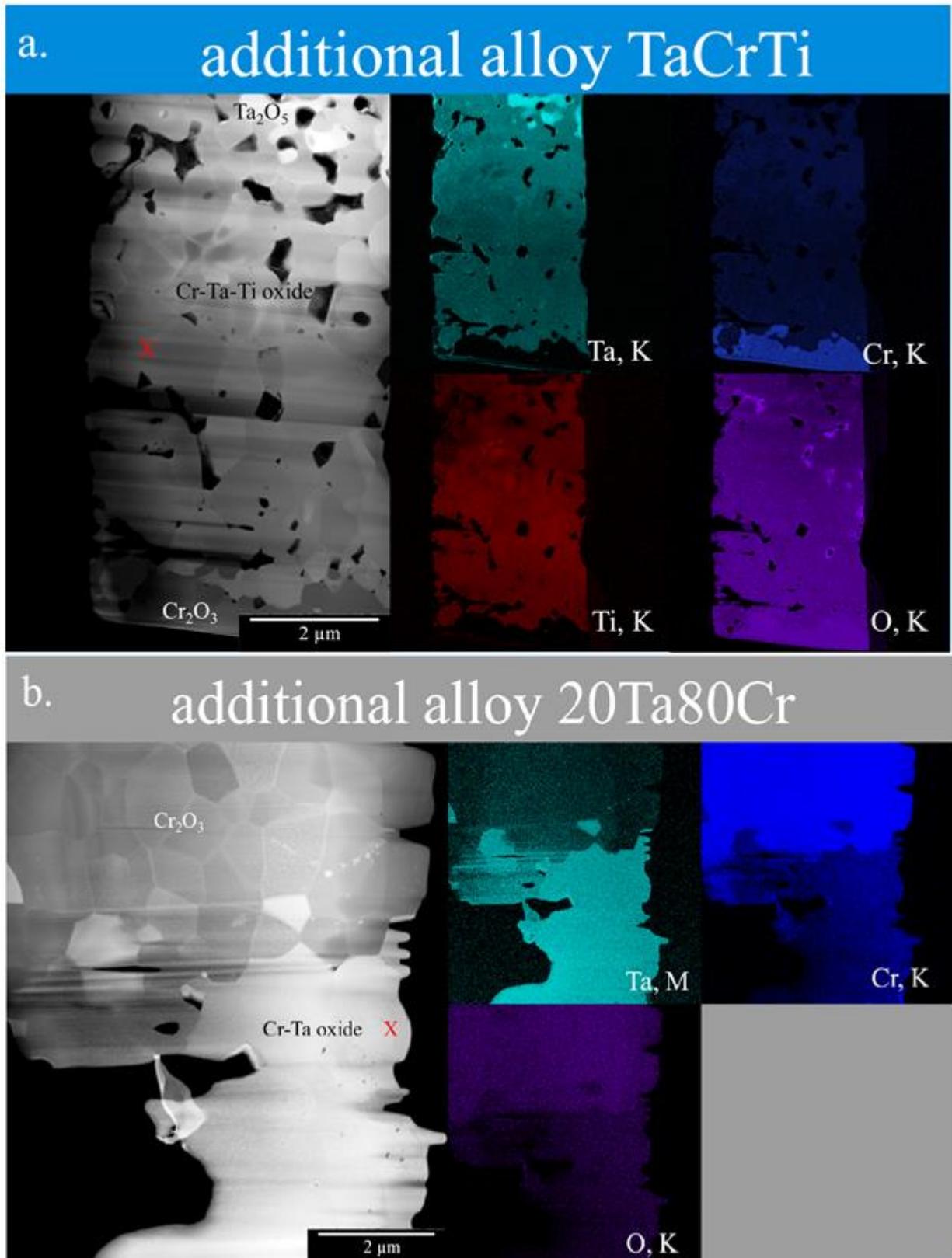
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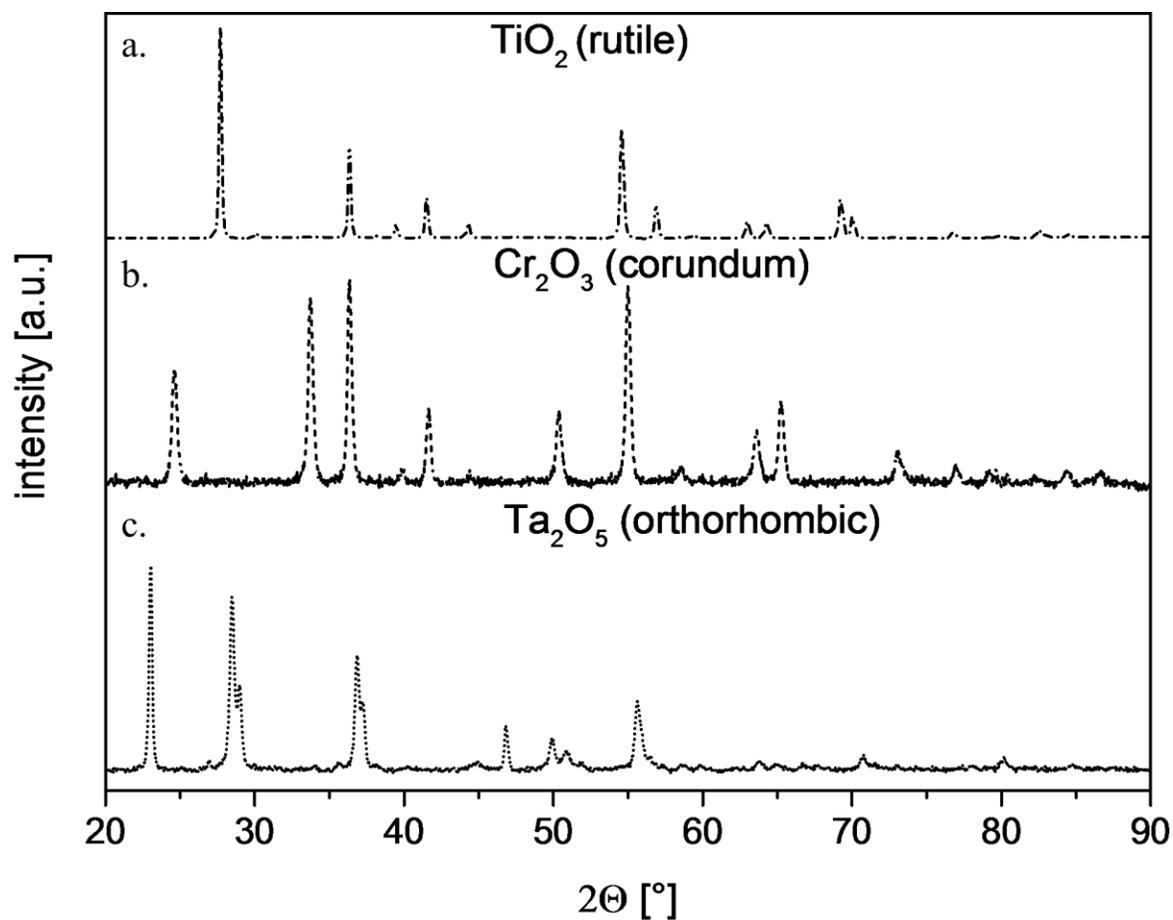
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 750 **Fig S. 5** BSE-SEM micrograph of the outer oxide scale formed on TaMoCrAl after exposure to air at 1200 °C for 24 h and the  
 751 corresponding EDX-mapping.  
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 754 **Fig S. 6** BSE-SEM images of formed oxide scale on additional alloys (a.) TaCrTi and (b.) 20Ta80Cr after exposure to air at 1200  
 755 °C for 24h. The vertical black line mark indicates the position of TEM lamella.  
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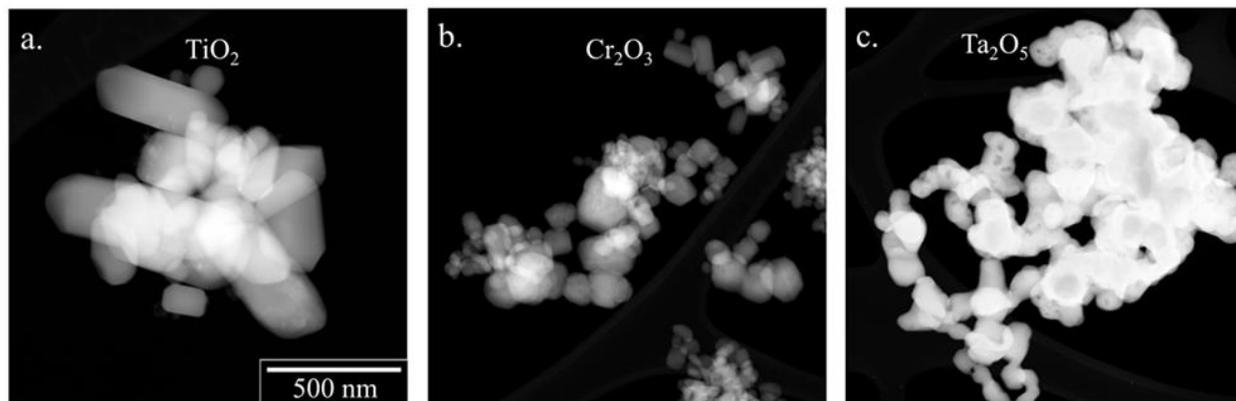


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 758 **Fig S. 7** HAADF-STEM micrographs with corresponding EDX mappings of the TEM lamellae of formed rutile Cr-Ta-(Ti) oxides  
 759 on additional alloys TaCrTi (a.) and (b.) 20Ta80Cr after oxidation to air at 1200 °C for 24 h. The “X” marks the location of the  
 760 EELS records.



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**Fig S. 8** XRD analysis of reference powder (a.)  $\text{TiO}_2$ , (b.)  $\text{Cr}_2\text{O}_3$  and (c.)  $\text{Ta}_2\text{O}_5$



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**Fig S. 9** HAADF-STEM micrographs of reference powder: a.  $\text{TiO}_2$ , b.  $\text{Cr}_2\text{O}_3$  and c.  $\text{Ta}_2\text{O}_5$ .